

ADD plant on



PNU **ADD**
ADVANCED DENTAL DEVICES

Advanced SLA Surface

(Sandblasted with Large grits and Acid etched)

- 1.5-1.6µm fine surface roughness for minimizing of peri-implantitis
- Reducing bacterial adhesion and effective cleansing of contaminated surface
- Inducing optimal osseointegration & Long-term success
- Easy application of simplified GBR procedure

Implant Comparison [Surface Roughness]

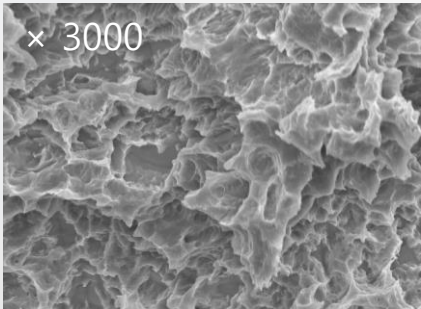
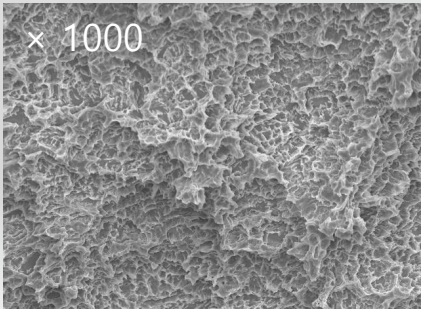
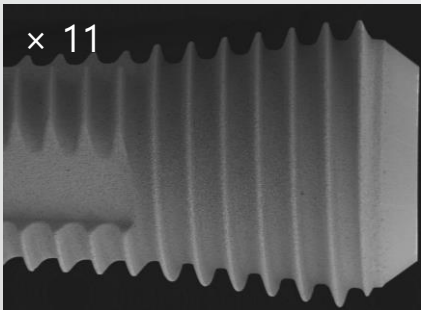
Other SLA
Fixture

ADDplant ON
Fixture

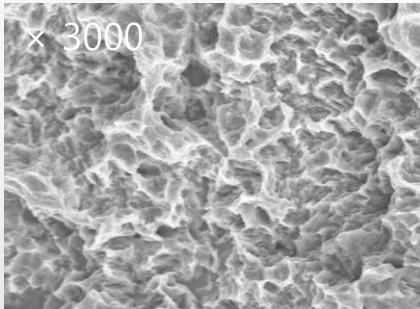
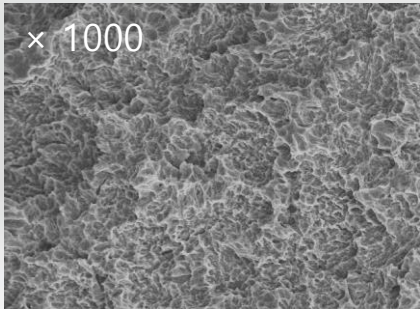
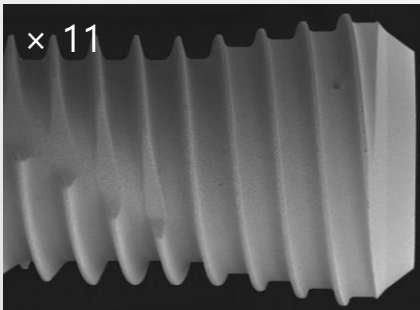


Surface roughness (µm)	Ra	Sa
Other SLA Fixture	2.5-3.0	2.5
ADDplant ON Fixture	1.5-1.6	1.7-1.8

Other SLA Fixture
(SEM Analysis)



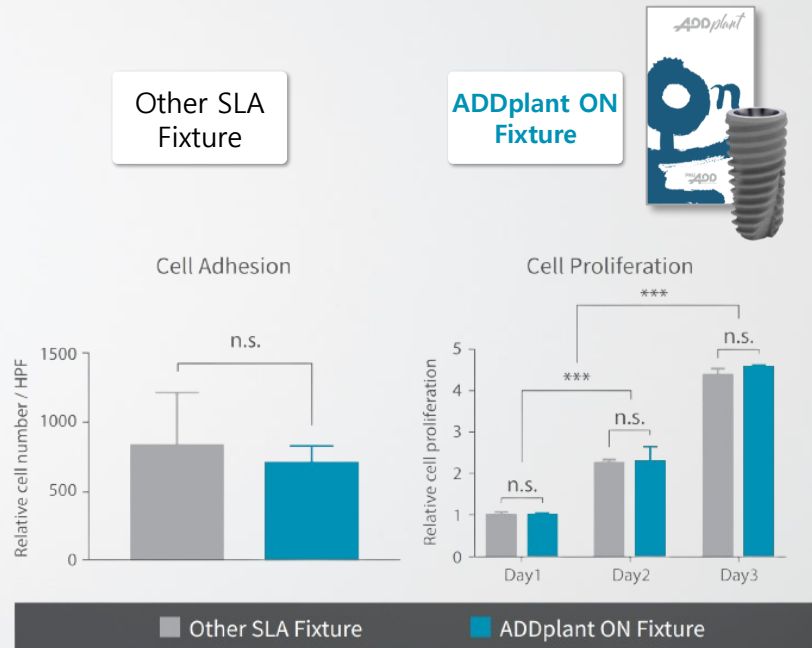
ADDplant ON Fixture
(SEM Analysis)



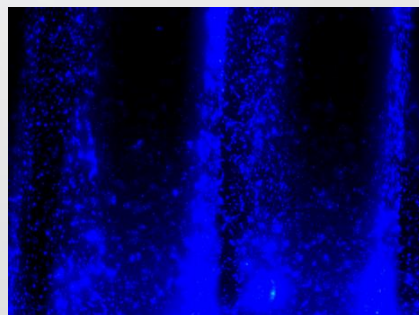
Advanced SLA Surface (Sandblasted with Large grits and Acid etched)

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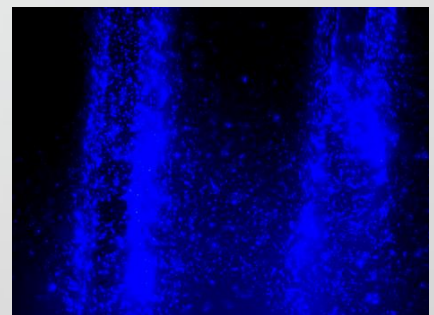
Implant Comparison [Cell Adhesion / Cell Proliferation]



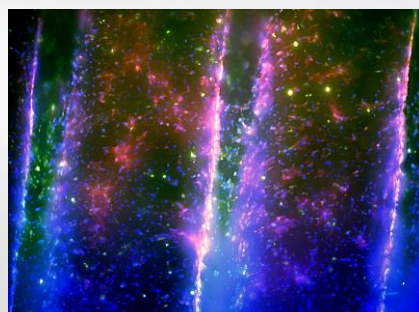
Other SLA Fixture
(Cell Adhesion)



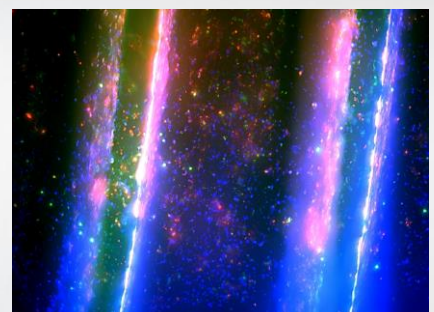
ADDplant ON Fixture
(Cell Adhesion)



Other SLA Fixture
(Cell Proliferation)



ADDplant ON Fixture
(Cell Proliferation)



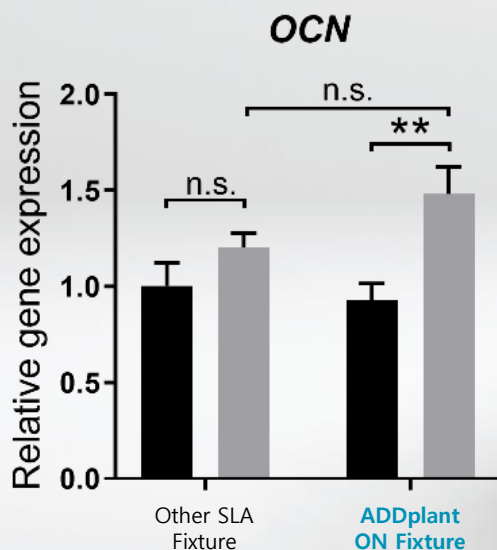
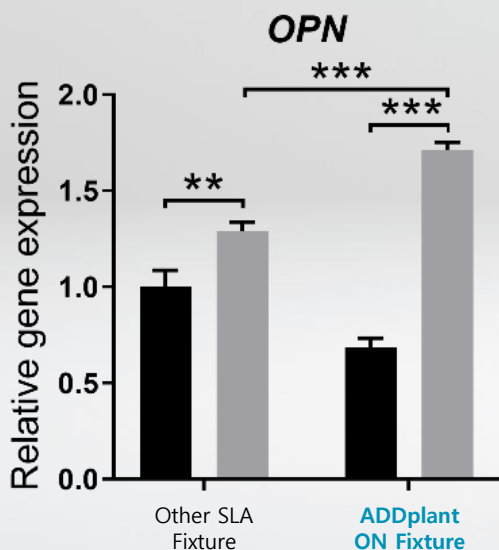
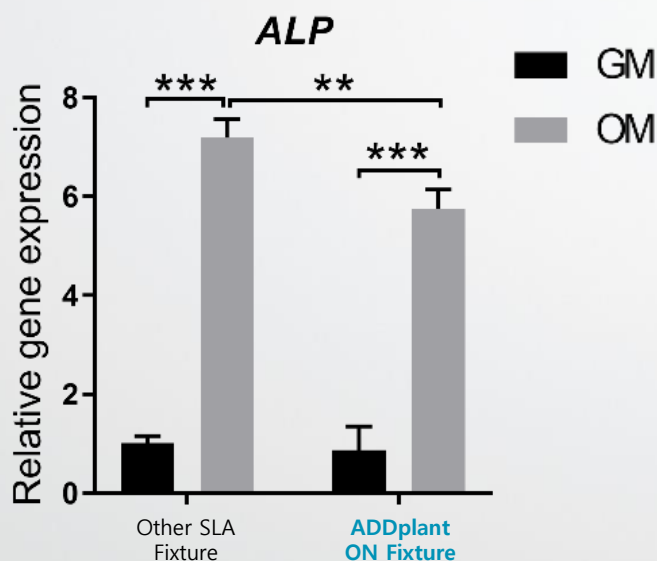
Advanced SLA Surface (Sandblasted with Large grits and Acid etched)

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Implant Comparison [Osteogenic differentiation]

Other SLA
Fixture

ADDplant ON
Fixture



Advanced SLA Surface (Sandblasted with Large grits and Acid etched)

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Implant Comparison [Osseointegration / In-vivo]

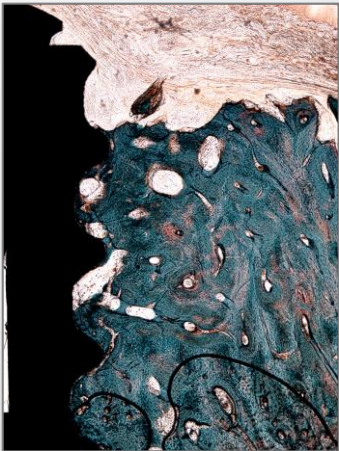
Other SLA
Fixture

ADDplant ON
Fixture

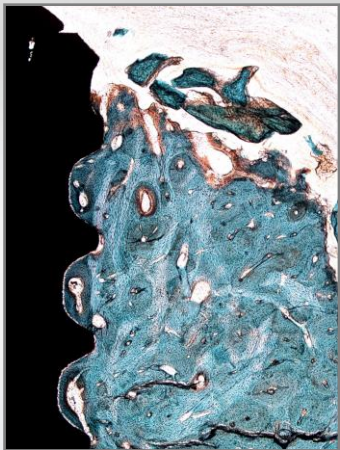
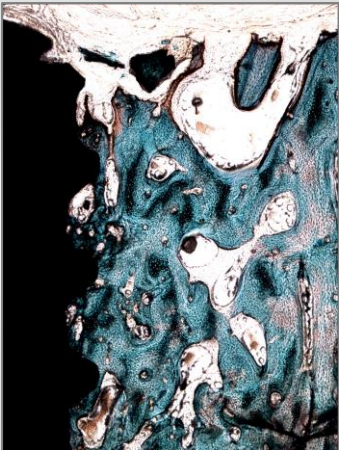
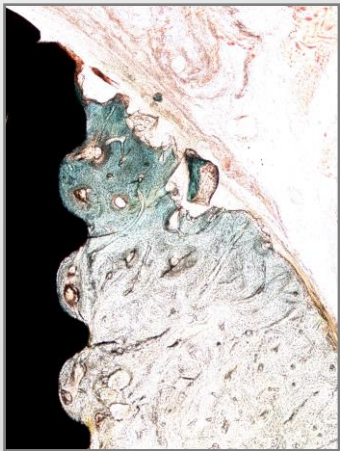


Histometric parameters (%)	BIC	ITBD
Other SLA Fixture	62.83 ± 11.82	66.54 ± 12.03
ADDplant ON Fixture	66.48 ± 10.06	72.26 ± 8.99

Other SLA Fixture
(SEM Analysis)



ADDplant ON Fixture
(SEM Analysis)



Clean Implant surface

- **Total 8-cleasing steps** thorough under vacuum condition
- Efforts to create a clean surface, No acid residues and impurities



Within 0.5 PPM (1mg/ L) for ion detection
NO₂, Br, PO₄ anions and heavy metals such as
Ni are not detected.

ADDplant ON Clinical Data

Research subjects	Time frame	Implantation quantity	Failure quantity	<u>Survival Rate</u>	Failure Rate ²
Korea Medical Institutions ¹ (121 locations)	2018.11.1 2 ~ 2024.05.0 1	105,618 ea	1,791 ea	98.3 %	1.7 %

¹ Including university dental hospital, dental clinics, medical device companies

² Including order errors and exchanges before product use.(1%)

R&D cooperative organizations

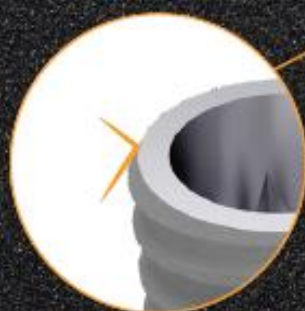
1. School of Dentistry, Pusan National University, Republic of Korea
2. Dr. Reuben Kim
Professor and Chair in the Section of Restorative Dentistry , Divison of Constitutive and Regenerative Sciences , at the University of California Los Angeles (UCLA) School of Dentistry.
3. Prof. Jung-Bo Huh and Hyung-Joon Kim, School of Dentistry, Pusan National University, Republic of Korea

11° tapered, internal conical connection

- Allow tight sealing between implant and abutment interface
- Maximize abutment compatibility
- Prevent micro-sinking of abutment

Platform switching with wider width on superior area of fixture

- Minimize bone loss and maintain bone level
- Sufficient tissue barrier formation



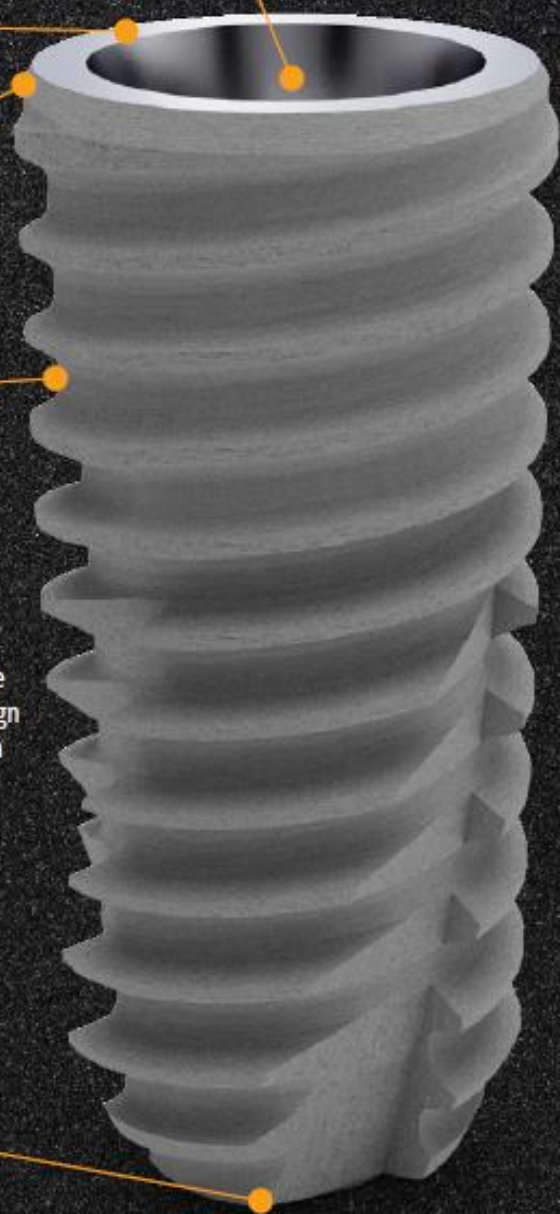
Open Thread & High stability

- Easy adjustment of insertion depth with minimum resistance
- Fast insertion due to the double-threaded and tapered body design
- Increase contact area between 0.9 thread pitch and results in increasing of stability and osseointegration



Flat end design with 3-wide cutting edge

- Improvement of comfortable fixation by 3-wide cutting edge
- Minimize bone destruction by self-tapping design of 3-wide cutting edge
- Reduction of bone perforation by flat end design

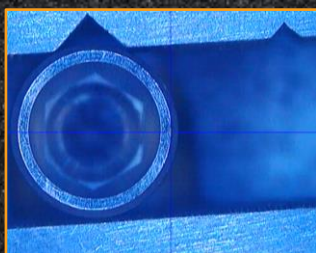


High Strength & Fracture-resistant Fixture

- About **11%** thicker than other products on superior area of fixture
- Reducing the thread depth in cervical area of fixture
- Grade 4 titanium features excellent resistance to corrosion and fatigue as well as high strength



Other SLA Fixture
(0.225mm)



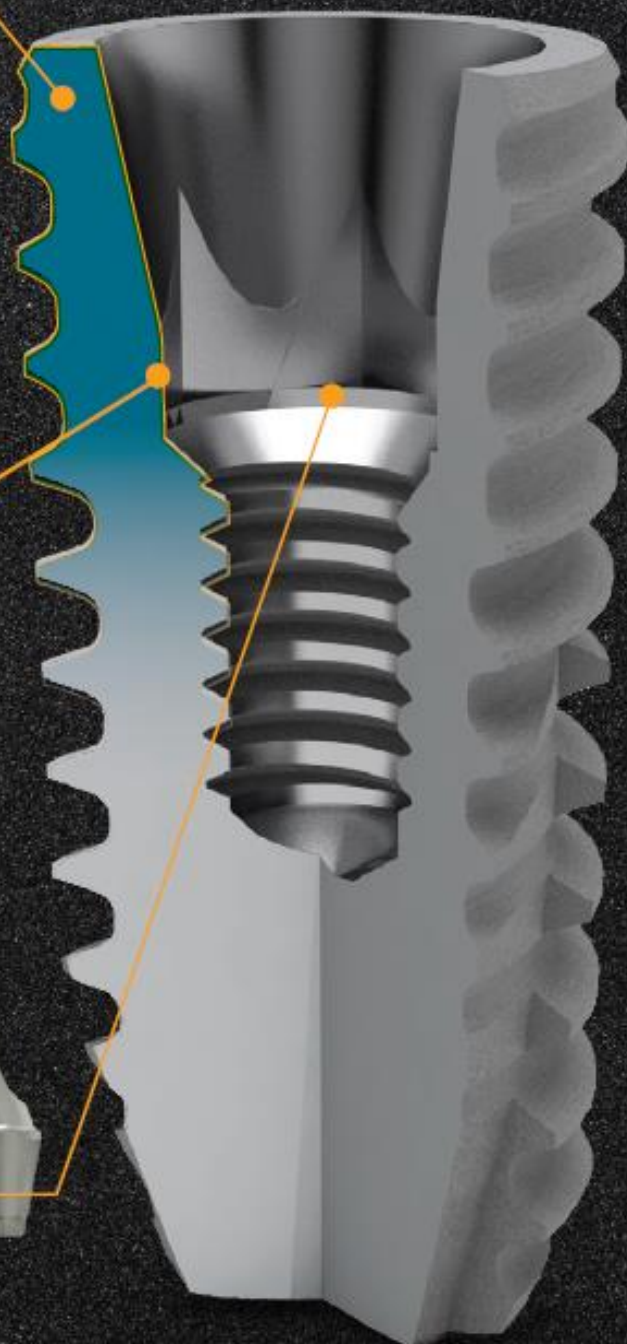
ADDplant ON Fixture
(0.25mm)

+ 11 %

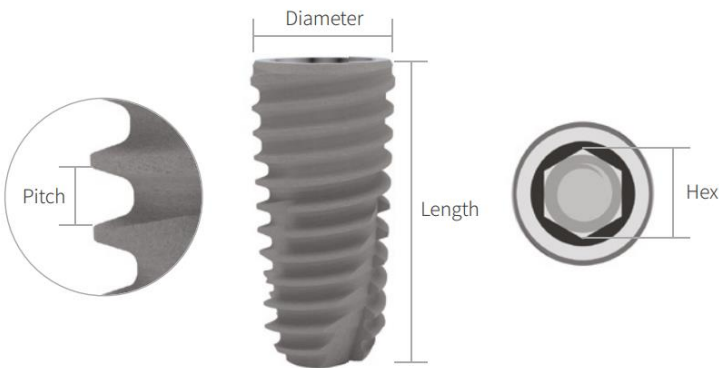


Internal conical connection

- Allow tight sealing between implant and abutment interface



Fixture



D Ø3.5	L	8.5 mm	10 mm	11.5 mm	13 mm
M Hex 2.1		ASM3508N	ASM3510N	ASM3511N	ASM3513N
Pitch 0.8					



D Ø4.0	L	7.0 mm	8.5 mm	10 mm	11.5 mm	13 mm
R Hex 2.5		ASR4007NS	ASR4008NS	ASR4010NS	ASR4011NS	ASR4013NS
Pitch 0.8						



D Ø4.5	L	7.0 mm	8.5 mm	10 mm	11.5 mm	13 mm
R Hex 2.5		ASR4507NS	ASR4508NS	ASR4510NS	ASR4511NS	ASR4513NS
Pitch 0.8						



D Ø5.0	L	7.0 mm	8.5 mm	10 mm	11.5 mm	13 mm
R Hex 2.5		ASR5007NS	ASR5008NS	ASR5010NS	ASR5011NS	ASR5013NS
Pitch 0.9						



D Ø5.5	L	7.0 mm	8.5 mm	10 mm	11.5 mm	13 mm
R Hex 2.5		ASR5507NS	ASR5508NS	ASR5510NS	ASR5511NS	ASR5513NS
Pitch 0.9						



D Ø6.0	L	7.0 mm	8.5 mm	10 mm	11.5 mm	13 mm
W Hex 2.5		ASW6007NS	ASW6008NS	ASW6010NS	ASW6011NS	ASW6013NS
Pitch 1.0						



D Ø7.0	L	7.0 mm	8.5 mm	10 mm	11.5 mm	13 mm
W Hex 2.5		ASW7007NS	ASW7008NS	ASW7010NS	ASW7011NS	ASW7013NS
Pitch 1.0						